

Crystal structural refinement of the new compound TmAlB_{14}

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Abstract

Single crystals of the new phase TmAlB_{14} were grown using the high-temperature solution method. The crystal structure of TmAlB_{14} was refined from X-ray powder diffraction data using the Rietveld method. The structure is of MgAlB_{14} -type with the space group Imma and unit cell parameters $a = 5.8212(3) \text{ \AA}$, $b = 10.3837(2) \text{ \AA}$ and $c = 8.1762(3) \text{ \AA}$. The final, conventional R -value and profile R -value are 0.031 and 0.064, respectively. The structure is characterized by a partial occupancy of both metal positions and a splitting of the thulium atomic position.

1. Introduction

Binary and ternary borides, crystallizing in the MgAlB_{14} -type structure, were recently reviewed and discussed by Korsukova [1]. In addition to the earlier studied phases of this type [2–7], new rare earth ternary borides REAlB_{14} were prepared for $\text{RE} = \text{Y}$, Tb, Dy, Ho, Er, Yb, and Lu [8–11]. In the present paper we report the preparation and structure refinement of TmAlB_{14} using the Rietveld method.

2. Experimental details

Single crystals of TmAlB_{14} were prepared by high temperature solution growth from aluminium melts [10] under an inert gas flow. The purities of the starting materials were 99.7–99.9 wt.%, better than 99 wt.%, and 99.99 wt.% for thulium, amorphous boron and aluminium, respectively. The atomic ratio of thulium to boron is 1:14, and the concentration of boron in aluminium melt is 1.9 wt.%. A vertical, resistively heated furnace was used. The mixture was heated at 1400°C for 4 h, then cooled to room temperature at a cooling rate of 100°C h^{-1} . The matrix was dissolved with dilute hydrochloric acid (1:3). Crystals were obtained ranging up to more than 1 mm in size.

Phase analysis was performed by X-ray powder diffraction using a Guinier–Hägg camera with $\text{CuK}\alpha_1$ radiation ($\lambda = 1.540598 \text{ \AA}$) and semiconductor-grade

silicon ($a = 5.431065 \text{ \AA}$) as internal calibration standard [12]. The intensity profile was measured with a computer-controlled microdensitometer [13]. The orthorhombic unit-cell parameters were determined from least-squares refinement [14].

The X-ray powder profile refinement was performed with a VAX computer using a local modification of the Rietveld program LHPM1 by Wiles and Young [15] and Hill and Howard [16]. Since the sample contained calibration Si and some agate from the mortar, used for the pulverization of the TmAlB_{14} crystals, the whole refinement procedure was carried out on three phases (TmAlB_{14} , Si and $\alpha\text{-SiO}_2$) simultaneously. The pseudo-Voigt function was used to describe the peak profile shape. The initial value for the positional parameters and the occupancy factors of both metal positions were taken from the single crystal study of MgAlB_{14} [2]. Initially the scale factor, positional and temperature parameters were refined. No satisfactory convergence was, however, obtained until the occupancy factors for thulium and aluminium atoms were allowed to be refined. Even lower agreement indices were obtained, when the thulium position was split and the x value of the $8i$ position allowed to be refined.

Crystals were analyzed using an ARL electron microprobe (20 kV accelerated voltage). Five crystals were analyzed with a total of 17 testing points. There were some differences between the crystals. The standard deviations given below were estimated using the formula

$$\sigma = \sqrt{\frac{\sum_i^N (x_i - \bar{x})^2}{N - 1}}$$

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TABLE 1. Final structure data for $\text{Tm}_{0.52}\text{Al}_{0.58}\text{B}_{14}$. Estimated standard deviations in parentheses. Space group Imma (No. 74)

| Atom | Position | x | y | z | B_{iso} (\AA^2) | Occupancy |
|----------------|----------|------------|------------|------------|-------------------------------------|-----------------------|
| Tm | 8i | 0.0271(7) | 1/4 | 0.6407(2) | 0.42(6) | 0.262(3) ^a |
| Al | 4c | 1/4 | 1/4 | 1/4 | 1.2(3) | 0.58(1) |
| B ₁ | 8h | 0 | 0.1738(8) | 0.9569(13) | 1.1(3) | 1 |
| B ₂ | 8h | 0 | 0.1510(8) | 0.3718(15) | 1.4(3) | 1 |
| B ₃ | 8h | 0 | 0.0857(10) | 0.1697(15) | 2.3(3) | 1 |
| B ₄ | 16j | 0.1625(11) | 0.0642(8) | 0.8383(11) | 2.5(3) | 1 |
| B ₅ | 16j | 0.2350(13) | 0.0810(8) | 0.4501(10) | 1.5(3) | 1 |

^aThe occupancy of the hole is 0.524(6).

The microprobe instrument does not permit a quantitative analysis of the light element boron and accordingly the concentration of boron is given by difference only. The composition as obtained from microprobe analysis is $\text{Tm}_{0.57(2)}\text{Al}_{0.62(3)}\text{B}_{14}$ with standard deviations given in parentheses.

3. Results and discussion

The unit cell dimensions of crystalline TmAlB_{14} are $a = 5.8212(3)$ \AA , $b = 10.3837(2)$ \AA and $c = 8.1762(3)$ \AA , respectively. The structure refinement was based on the recording of 3550 intensity values in the 2θ -range 9.0° – 90.1° . A total of 29 parameters were refined. The final Bragg R -value, unweighted profile R -value and weighted profile R -value were 0.031, 0.064, 0.086, respectively. The final positional, thermal and occupancy parameters are given in Table 1. A list of the observed and calculated Bragg angles and intensities for the low angle reflections ($Q < 0.313$, with Q defined as $4\sin^2\theta/\lambda^2$) is given in Table 2. Interatomic distances are listed in Table 3.

The atomic arrangement of the MgAlB_{14} -type structure has been described in detail in several recent publications [1–3, 11] and in the present context we only mention the most conspicuous features. The structure is built up of slightly deformed boron icosahedra (B(1), B(3)–B(5)), which are interconnected via external B–B contacts or via non-icosahedral boron atoms (B(2)). The metal atoms are accommodated in interstitial holes: aluminium at an average distance of 2.26 \AA from 12 boron neighbours and thulium at an average distance of 2.72 \AA from 18 boron neighbours. Both metal atoms display the shortest interatomic distance (and therefore the shortest metal–boron bond) to the non-icosahedral B(2) atom (2.04 \AA for Al–B(2) and 2.44 \AA for Tm–B(2), respectively). This supports the conclusion by Higashi [6] that metal atoms bond more strongly to non-icosahedral than to icosahedral boron atoms.

The rigid three-dimensional boron network of the MgAlB_{14} -type phases is relatively independent of metal

TABLE 2. X-ray diffraction data of $\text{Tm}_{0.52}\text{Al}_{0.58}\text{B}_{14}$ for the low angle reflections ($0.024 < Q < 0.313$)

| $h\ k\ l$ | Θ_{calc} | Θ_{obs} | $(I/I_1)_{\text{calc}}$ | $(I/I_1)_{\text{obs}}$ |
|-----------|------------------------|-----------------------|-------------------------|------------------------|
| 0 1 1 | 6.887 | 6.894 | 862 | 700 |
| 0 2 0 | 8.532 | 8.536 | 521 | 550 |
| 1 0 1 | 9.348 | 9.353 | 234 | 214 |
| 0 0 2 | 10.861 | — | 11 | 0 |
| 1 2 1 | 12.709 | 12.705 | 769 | 756 |
| 0 2 2 | 13.876 | 13.886 | 53 | 86 |
| 0 3 1 | 13.985 ^a | — | 284 | — |
| 1 1 2 | 13.999 ^a | 13.994 | 716 | 1000 |
| 2 0 0 | 15.346 | 15.342 | 178 | 157 |
| 2 1 1 | 16.891 | 16.885 | 505 | 554 |
| 0 1 3 | 16.990 | 16.971 | 125 | 197 |
| 0 4 0 | 17.261 | 17.259 | 103 | 84 |
| 2 2 0 | 17.662 | 17.658 | 498 | 481 |
| 1 0 3 | 18.184 | 18.134 | 210 | 230 |
| 1 3 2 | 18.676 | 18.671 | 707 | 644 |
| 2 0 2 | 18.985 | — | 9 | 0 |
| 1 4 1 | 19.772 | 19.766 | 223 | 207 |
| 1 2 3 | 20.215 | 20.209 | 740 | 727 |
| 0 4 2 | 20.579 | 20.574 | 58 | 57 |
| 2 2 2 | 20.925 | — | 17 | 0 |
| 2 3 1 | 21.001 | 20.996 | 575 | 629 |
| 0 3 3 | 21.084 | 21.079 | 199 | 188 |
| 0 0 4 | 22.138 | 22.138 | 102 | 110 |
| 0 5 1 | 22.500 | 22.500 | 129 | 144 |
| 2 1 3 | 23.218 | 23.216 | 62 | 73 |
| 2 4 0 | 23.428 | 23.425 | 81 | 65 |
| 0 2 4 | 23.891 | 23.893 | 78 | 101 |
| 1 1 4 | 23.968 | 23.964 | 93 | 103 |
| 3 0 1 | 24.079 | 24.075 | 44 | 60 |
| 1 4 3 | 25.507 | 25.505 | 207 | 159 |

^aThese two diffraction lines overlap in the observed reflections.

atoms accommodated in the structure. However, there are two characteristics that distinguish the phases from each other. The first is the partial occupancies of the metal positions and the second is the split $8i$ position of the RE atom. There is a good agreement between the occupancy of the aluminium position as obtained from the structure refinement, 0.58(1) (Table 1), and that obtained from microprobe analysis, 0.62(3). For TmAlB_{14} this occupancy is significantly lower than the values obtained for $\text{Er}_{0.62}\text{Al}_{0.73}\text{B}_{14}$ and for $\text{Y}_{0.62}\text{Al}_{0.71}\text{B}_{14}$, respectively [11]. The Al atoms of TmAlB_{14} form a

TABLE 3. Interatomic distances in $\text{Tm}_{0.52}\text{Al}_{0.58}\text{B}_{14}$. Distances listed are all $\text{M-M} < 3.70 \text{ \AA}$, $\text{M-B} < 3.60 \text{ \AA}$, $\text{B-B} < 2.10 \text{ \AA}$

| Atoms | Distances | Atoms | Distances |
|----------|-----------|------------|-----------|
| Tm-Tm | 0.316(8) | B(1)-B(1) | 1.582(17) |
| -2B(2) | 2.443(12) | -2B(4) | 1.769(11) |
| -2B(4) | 2.637(8) | -B(3) | 1.966(16) |
| -2B(5) | 2.641(8) | -2B(5) | 1.971(9) |
| -2B(4) | 2.649(7) | | |
| -2B(1) | 2.708(11) | | |
| -2B(4) | 2.748(8) | B(2)-2B(5) | 1.676(9) |
| -2B(5) | 2.799(8) | -B(3) | 1.786(18) |
| -2B(4) | 2.873(7) | -B(2) | 2.058(17) |
| -2B(1) | 2.973(5) | | |
| -Tm | 3.151(7) | | |
| -2B(1) | 3.268(5) | | |
| -2Tm | 3.416(2) | | |
| -Al | 3.448(2) | B(3)-2B(4) | 1.823(11) |
| -Al | 3.579(2) | -2B(5) | 1.828(9) |
| -Tm | 3.688(7) | | |
| Al-4B(2) | 2.042(8) | | |
| -4B(3) | 2.337(8) | | |
| -4B(5) | 2.410(9) | B(4)-B(4) | 1.767(15) |
| -2Al | 2.911(1) | -B(5) | 1.838(12) |
| -4B(1) | 2.913(9) | -B(5) | 1.861(11) |
| -4B(4) | 3.380(7) | -B(4) | 1.892(8) |

straight chain with Al-Al distances of 2.91 \AA (Table 3) at full occupancy.

Depending on the splitting $8i$ position, the thulium atoms form a slightly irregular zig-zag chain with Tm-Tm distances 0.32 \AA , 3.15 \AA , 3.416 \AA and 3.69 \AA . The first-mentioned distance originates from the $+x$ and $-x$ coordinates of the $8i$ position, and does not, of course, occur in the structure due to the low crystallographic occupancy of 0.26 (involving a *hole* occupancy of 0.52). The splitting means that a static positional disorder of the thulium atoms occurs with the thulium atoms randomly distributed in the different unit cells among $+x$ and $-x$ positional coordinates ($+0.02372$, 0.25 , 0.64219). It is also noted that the distance 3.416 \AA is close to the average of 3.15 \AA and 3.69 \AA . A similar splitting of the $4e$ position has been observed for $\text{Mg}_{0.78}\text{Al}_{0.75}\text{B}_{14}$ [3], $\text{Y}_{0.62}\text{Al}_{0.71}\text{B}_{14}$ and $\text{Er}_{0.62}\text{Al}_{0.73}\text{B}_{14}$ [11].

Though the reasons for this splitting are unknown as yet, it seems likely that the splitting is favoured by the partial occupancies of the metal positions in general and of the $4e$ position in particular. Thus, in the isostructural compounds LiAlB_{14} [6], $\text{NaB}_{0.8}\text{B}_{14}$ [17] and Mg_2B_{14} [5], where the $4e$ position is almost completely occupied by the lithium, sodium and magnesium atoms, respectively. No splitting was found. On the other hand,

in the structure of HoAlB_{14} no splitting of the $4e$ position was reported either, in spite of the partial occupancies of the metal sites by holmium and aluminium atoms [8]. Structural studies on other representatives of this structure family might throw some light on this problem.

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